IN THE UNITED STATES PATENT AND TRADEMARK OFFICE

In re Application of:)
CHIBA, Tatsuo, et al.	Atty. Docket No.: TSUK 0005
Serial No (corresponding to PCT/JP00/04028 filed 21 June 2000)	3-12-02
Filed: Herewith	
For: PHOTOSENSITIVE ELEMENT,)
PHOTOSENSITIVE ELEMENT ROLL,)
PROCESS FOR THE PREPARATION	
OF RESIST PATTERN USING THE	
SAME, RESIST PATTERN, RESIST)
PATTERN LAMINATED) .
SUBSTRATE, PROCESS FOR THE	
PREPARATION OF WIRING	Date: 20 December 2001
PATTERN AND WIRING PATTERN	

INFORMATION DISCLOSURE STATEMENT

BOX: PCT (DO/EO/US)

Assistant Commissioner for Patents

Washington, D. C. 20231

Sir:

This is an Information Disclosure Statement with regard to the above-identified application. Copies of each of the documents listed in the attached Form PTO/SB/08A are attached.

Also attached is a copy of the Search Report issued on October 2, 2000 in the corresponding international application. Since all of the documents cited herein were cited in said Search Report, it is believed that the relevancy of each document cited is clear from the Search Report. Accordingly, no further comment in regard to the disclosures of these documents is believed to be required.

It is respectfully requested that the attached documents be considered and officially

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cited, and that a copy of the Form PTO/SB/08A, initialed by the Examiner to indicate that the documents have been considered, be returned to the applicants.

It is believed that the present Information Disclosure Statement complies with the requirements of 37 C.F.R. §§ 1.97-8, but if a fee should be required, authorization is hereby given to deduct from Deposit Account No. 50-1281.

Respectfully submitted,

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